This listing of claims will replace all prior versions and listings of claims in the

application:

LISTING OF CLAIMS:

1. (original): A flip-chip-type gallium nitride compound semiconductor light-emitting

device comprising a substrate, an n-type semiconductor layer, a light-emitting layer, and a p-type

semiconductor layer, a negative electrode provided on said n-type semiconductor layer, and a

positive electrode provided on said p-type semiconductor layer, the layers being successively

provided atop said substrate in this order and being composed of a gallium nitride compound

semiconductor, wherein said positive electrode has a three-layer structure comprising an ohmic

electrode layer composed of rhodium which is in contact with said p-type semiconductor layer,

an adhesion layer composed of titanium which is provided on said ohmic electrode layer and has

a thickness of 10 Å or more, and a bonding pad layer provided on said adhesion layer and being

composed of a metal selected from the group consisting of gold, aluminum, nickel, and copper,

or composed of an alloy containing at least one of these metals.

2. (original): A flip-chip-type gallium nitride compound semiconductor light-emitting

device according to claim 1, wherein said adhesion layer has a thickness of 500 Å to 3,000 Å.

3. (original): A flip-chip-type gallium nitride compound semiconductor light-emitting

device according to claim 2, wherein said adhesion layer has a thickness of 1,000 Å or more.

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4. (currently amended): A flip-chip-type gallium nitride compound semiconductor light-

emitting device according to claim 1 any one of claims 1 to 3, wherein said ohmic electrode layer

has a thickness of 100 Å to 3,000 Å.

5. (original): A flip-chip-type gallium nitride compound semiconductor light-emitting

device according to claim 4, wherein said ohmic electrode layer has a thickness of 500 Å to

2,000 Å.

6. (currently amended): A flip-chip-type gallium nitride compound semiconductor light-

emitting device according to claim 1 any one of claims 1 to 5, wherein said bonding pad layer has

a thickness of at least 1,000 Å.

7. (original): A flip-chip-type gallium nitride compound semiconductor light-emitting

device according to claim 6, wherein said bonding pad layer has a thickness of 3,000 Å to 5,000

Å.

8. (currently amended): A flip-chip-type gallium nitride compound semiconductor light-

emitting device according to claim 1 any one of claims 1 to 7, wherein said bonding pad layer is

composed of gold.

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light-emitting device, wherein said positive electrode has a three-layer structure comprising an ohmic electrode layer composed of rhodium which is brought into contact with a p-type semiconductor layer of said compound semiconductor light-emitting device, an adhesion layer composed of titanium which is provided on said ohmic electrode layer and has a thickness of 10

9. (original): A positive electrode for use in a gallium nitride compound semiconductor

composed of titanium which is provided on said ohmic electrode layer and has a thickness of 10

Å or more, and a bonding pad layer provided on said adhesion layer, said bonding pad layer

being composed of a metal selected from the group consisting of gold, aluminum, nickel, and

copper, or composed of an alloy containing at least one of these metals.

10. (original): A positive electrode for use in gallium nitride compound semiconductor

light-emitting device according to claim 9, wherein said adhesion layer has a thickness of 500 Å

to 3,000 Å.

11. (currently amended): A positive electrode for use in a gallium nitride compound

semiconductor light-emitting device according to claim 9-or 10, wherein said adhesion layer has

a thickness of 1,000 Å or more.

12. (currently amended): A light-emitting diode comprising a flip-chip-type gallium

nitride compound semiconductor light-emitting device according to claim 1 any one of claims 1

to 8.

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13. (currently amended): A lamp comprising a flip-chip-type gallium nitride compound semiconductor light-emitting device according to <u>claim 1 any one of claims 1 to 8</u>.